

United States Patent and Trademark Office



UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450 www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/605,585	10/10/2003	Masaki Takaoka	RHM-US020052	2584
22919 7	7590 11/01/2006		EXAMINER	
GLOBAL IP COUNSELORS, LLP			NADAV, ORI	
1233 20TH STREET, NW, SUITE 700 WASHINGTON, DC 20036-2680		•	ART UNIT	PAPER NUMBER
	, 20 2000 2000	•	2811	
			DATE MAILED: 11/01/2006	

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)				
	10/605,585	TAKAOKA ET AL.				
Office Action Summary	Examiner	Art Unit				
	Ori Nadav	2811				
The MAILING DATE of this communication app Period for Reply	ears on the cover sheet with the	correspondence address				
A SHORTENED STATUTORY PERIOD FOR REPLY WHICHEVER IS LONGER, FROM THE MAILING DA - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory period w - Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATION (Section 2) In no event, however, may a reply be to the section of th	ON. imely filed m the mailing date of this communication. IED (35 U.S.C. § 133).				
Status						
1) Responsive to communication(s) filed on 29 Au	<u>ıgust 2006</u> .					
2a) ☐ This action is FINAL. 2b) ☑ This	action is non-final.					
3) Since this application is in condition for allowar	ice except for formal matters, p	rosecution as to the merits is				
closed in accordance with the practice under E	x parte Quayle, 1935 C.D. 11, 4	153 O.G. 213.				
Disposition of Claims						
4)⊠ Claim(s) <u>1,4 and 13</u> is/are pending in the application.						
4a) Of the above claim(s) is/are withdrawn from consideration.						
5) Claim(s) is/are allowed.						
6)⊠ Claim(s) <u>1,4 and 13</u> is/are rejected.		·				
7) Claim(s) is/are objected to.						
8) Claim(s) are subject to restriction and/or	election requirement.	·				
Application Papers						
9)☐ The specification is objected to by the Examiner.						
10) The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner.						
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).						
11)☐ The oath or declaration is objected to by the Ex		, ,				
Priority under 35 U.S.C. § 119						
12)☐ Acknowledgment is made of a claim for foreign	priority under 35 U.S.C. § 119(a	a)-(d) or (f).				
a) ☐ All b) ☐ Some * c) ☐ None of:						
1. Certified copies of the priority documents have been received.						
2. Certified copies of the priority documents have been received in Application No						
3. Copies of the certified copies of the priority documents have been received in this National Stage						
application from the International Bureau (PCT Rule 17.2(a)).						
* See the attached detailed Office action for a list	of the certified copies not receiv	red.				
Attachment(s)						
1) Notice of References Cited (PTO-892)	4) 🔲 Interview Summar					
2) Notice of Draftsperson's Patent Drawing Review (PTO-948)	Paper No(s)/Mail [
3) Information Disclosure Statement(s) (PTO/SB/08) Paper No(s)/Mail Date	5) Notice of Informal 6) Other:	гасел Арріюацоп				
U.S. Patent and Trademark Office PTOL-326 (Rev. 08-06) Office Ac	tion Summary P	art of Paper No./Mail Date 20061027				

Application/Control Number: 10/605,585

Art Unit: 2811

DETAILED ACTION

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claims 1 and 13 are rejected under 35 U.S.C. 102(b) as being anticipated by Ishibashi (5,202,281).

Ishibashi teaches in figures 3 or 4 and related text a semiconductor device, comprising:

a unitary and non-layered semiconductor substrate 4 comprising a thin portion that is thinner than adjacent portions of the semiconductor substrate, and a recessed portion formed below the thin portions;

wherein the etching rate of the thin portion is slower than that of the surrounding portions of the semiconductor substrate (since a dopant 3 is infused in the thin portion that is immediately adjacent in the at least one through hole),

at least one through hole is formed in the thin portion that extends from the recessed portion, and entirely through the thin portion to the upper surface of the semiconductor substrate 4.

Regarding claim 13, Ishibashi teaches that semiconductor substrate 4 has a specific resistance (column 3, lines 20-21). This means that the substrate must be doped.

Application/Control Number: 10/605,585

Art Unit: 2811

Therefore, by considering the "dopant" as the dopant with which the entire substrate is doped, then Ishibashi teaches a dopant is infused in the entire thin portion, as claimed.

Claim Rejections - 35 USC § 102/3

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claim 4 is rejected under 35 U.S.C. 102(b) as anticipated by or, in the alternative, under 35 U.S.C. 103(a) as obvious over Ishibashi

Ishibashi teaches in figures 3 or 4 and related text substantially the entire claimed structure, as applied to claim 1 above, except a thin portion is formed by means of a selective oxide film.

The claimed limitations of a thin portion being formed by means of a selective oxide film are process limitations which would not carry patentable weight in this claim drawn to a structure, because distinct structure is not necessarily produced.

Note that a "product by process" claim is directed to the product per se, no matter how actually made, In re Hirao, 190 USPQ 15 at 17 (footnote 3). See also In re Brown, 173 USPQ 685; In re Luck, 177 USPQ 523; In re Fessmann, 180 USPQ 324; In re Avery, 186 USPQ 161; In re Wertheim, 191 USPQ 90 (209 USPQ 554 does not deal with this issue); and In re Marosi et al., 218 USPQ 289, all of which make it clear that it is the

Art Unit: 2811

patentability of the final product per se which must be determined in a "product by process" claim, and not the patentability of the process, and that an old or obvious product produced by a new method is not patentable as a product, whether claimed in "product by process" claims or not. Note that the applicant has the burden of proof in such cases, as the above case law makes clear.

Response to Arguments

Applicant argues that the doped portion of the thin portion in the Ishibashi reference is not immediately adjacent to the through hole, but rather far removed from the through hole.

Positioning an element "immediately adjacent" or "far" from another element is a relative location, which would not specify the exact location of the first element with respect to the second element.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Ori Nadav whose telephone number is 571-272-1660. The examiner can normally be reached between the hours of 7 AM to 4 PM (Eastern Standard Time) Monday through Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Richard Elms can be reached on 571-272-1869. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Art Unit: 2811

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

O.N. 10/27/06 ORI NADAV PRIMARY EXAMINER TECHNOLOGY CENTER 2800